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CONFIRMATION NO. 3057

SERIAL NUMBER 10/761,842 RULE CLASS 430 GROUP ART UNIT 1752 ITL. 1058 (P1780) APPLICANTS Wang Yueh, Portland, OR; Ernisse S. Putna, Beaverton, OR; ***CONTINUING DATA ******** None SJL ***FOREIGN APPLICATIONS ******* None SJL IF REQUIRED, FOREIGN FILING LICENSE GRANTED ***O4/26/2004 Foreign Priority claimed yes Ino 35 USC 119 (a-d) conditions met Allowance SJL COUNTRY DRAWING CLAIMS											
Wang Yueh, Portland, OR; Ernisse S. Putna, Beaverton, OR; *** CONTINUING DATA *** None SJL IF REQUIRED, FOREIGN FILING LICENSE GRANTED ****OA/26/2004 Foreign Priority claimed yes no street yes no successful yes no suscensive yes no suscensive yes no suscensive yes no suscensive yes no heat after met verified and Acknowledged Examiner Signature Initials Acknowledged Examiner Signature Initials ADDRESS 21906 TROP PRUNER & HU, PC 8554 KATY FREEWAY SUITE 100 HOUSTON , TX 77024 TITLE Reducing outgassing of reactive material upon exposure of photolithography resists All Fees			01/21/2004 CLASS GF 430			GRC	1		ATTORNEY DOCKET NO. ITL.1058US (P17800)		
Emisse S. Putna, Beaverton, OR; **CONTINUING DATA **** None SJL **FOREIGN APPLICATIONS *** None SJL IF REQUIRED, FOREIGN FILING LICENSE GRANTED **04/26/2004 Foreign Priority claimed yes on Met after met SJL COUNTRY DRAWING CLAIMS CRAIT FREEWAY SUITE 100 HOUSTON , TX 77024 TITLE Reducing outgassing of reactive material upon exposure of photolithography resists FEES: Authority has been given in Paper No. Lo charge/credit DEPOSIT ACCOUNT NO. Grocessing Entire (Processing Entire) PECENTED **ON ON O	APPLICANTS										
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